



National Physical Laboratory

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

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Electromagnetics Science Leader  
National Physical Laboratory, UK

CCEM workshop “Future challenges in electrical metrology”, BIPM, Paris, 23 March 2017

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Focus on three 'new' measurement topics . . .

- I. Filling the gap between microwaves and photonics**
- II. Multi-physics – more than just microwaves**
- III. When digital becomes analogue**

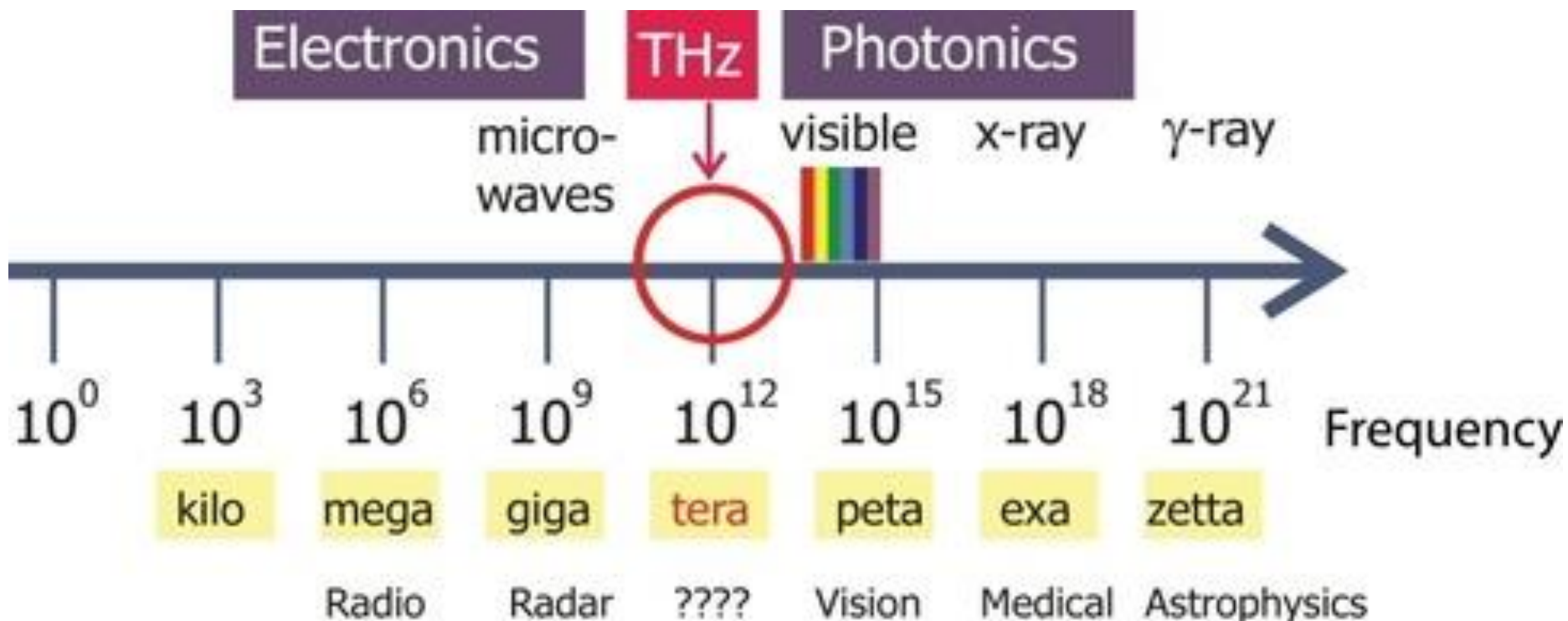
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

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# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Filling the gap between electronics and photonics

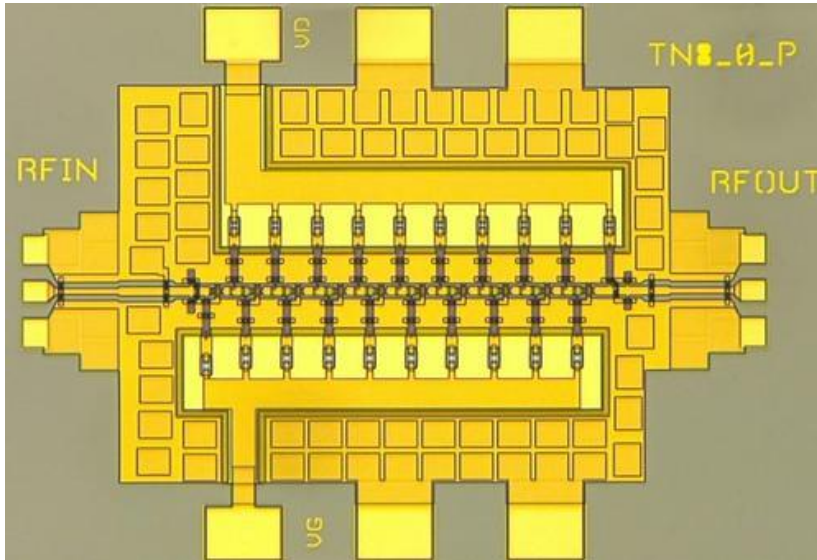


# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Many applications

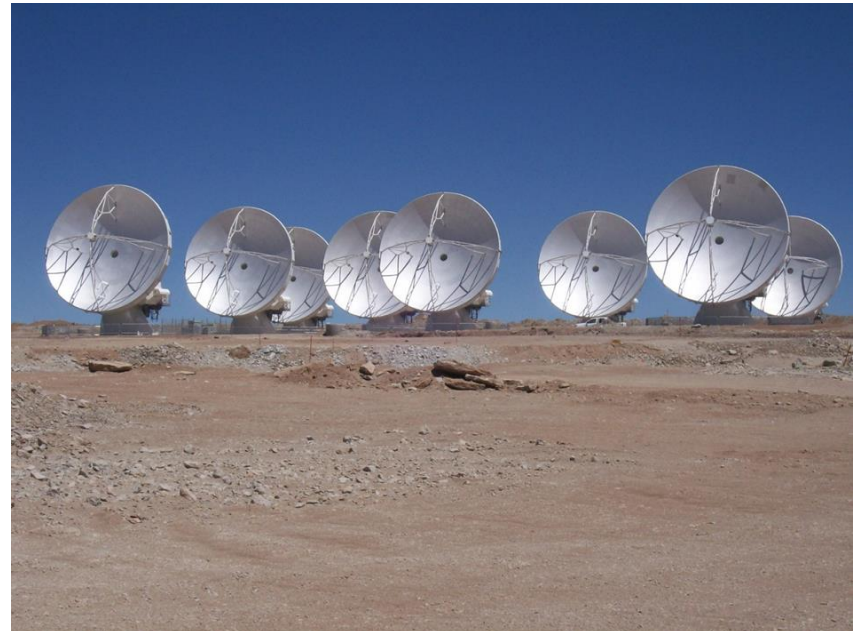
### THz electronics

Terahertz Monolithic Integrated Circuit (TMIC)  
InP amplifier (Northrop Grumman)



### Radio Astronomy

ALMA – Atacama Large Millimeter/submillimeter Array  
Location: Atacama desert, Northern Chile  
Telescope bandwidth: >950 GHz



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Many applications

### Security

Airports and stand-off detection

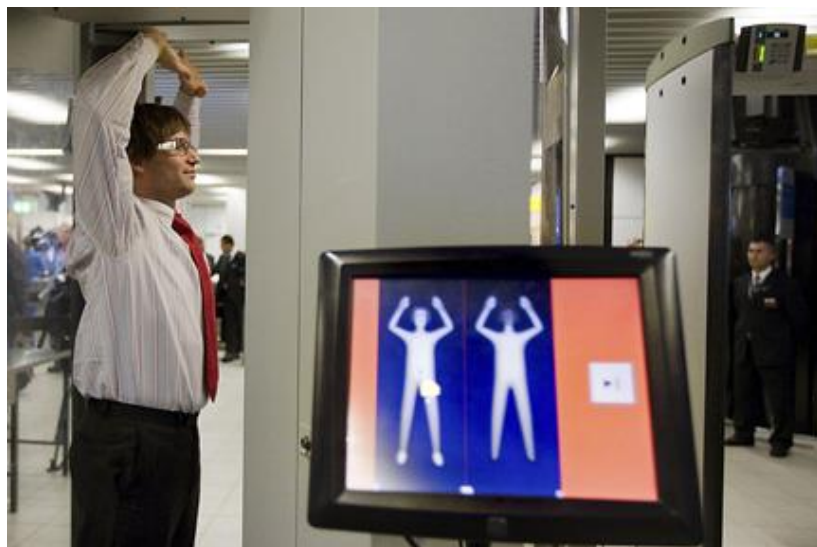
Detecting weapons and other terrorist threats

### Space

European Space Agency (ESA)

ISMAR - International Sub-Millimetre Airborne Radiometer Instrument

Observing precipitation and ice clouds (for climate change)



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

New measurements . . . going from GHz to THz

- **Instrumentation – waveguides**
- **Devices – on-wafer**

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

New measurements . . . going from GHz to THz

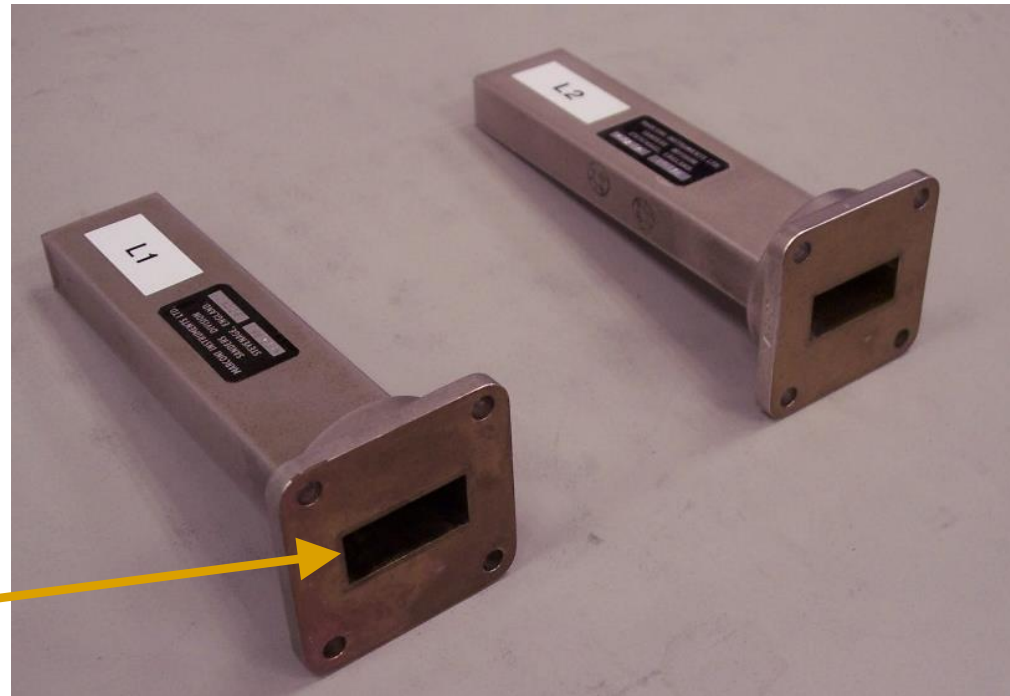
- **Instrumentation – waveguides**
- **Devices – on-wafer**



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Metal waveguides – some history

- Use of metallic waveguide dates back to the early/mid 20<sup>th</sup> century
- First 'popular' waveguide: X-band (8.2 – 12.4 GHz)
- X-band aperture size:  
0.9" × 0.4"  
23 mm × 10 mm



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

As frequencies get higher, waveguide gets smaller . . .

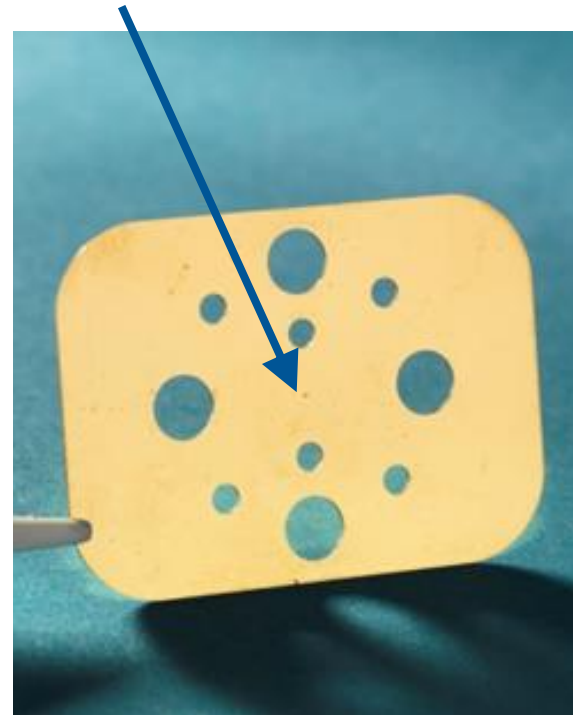
At 200 GHz

Aperture: 1.30 mm × 0.65 mm



At 1000 GHz (1 THz)

Aperture: 250 μm × 125 μm

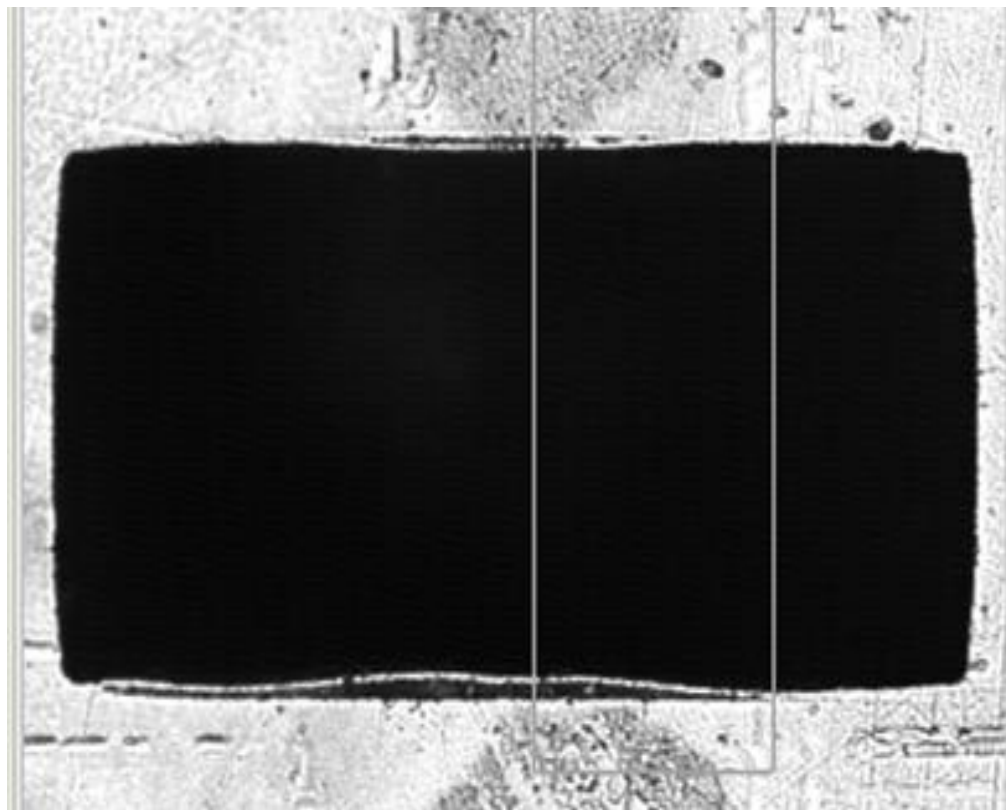


# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

1 THz waveguide . . . seen under a microscope  
(during a dimensional measurement)

Aperture =

$250\ \mu\text{m} \times 125\ \mu\text{m}$



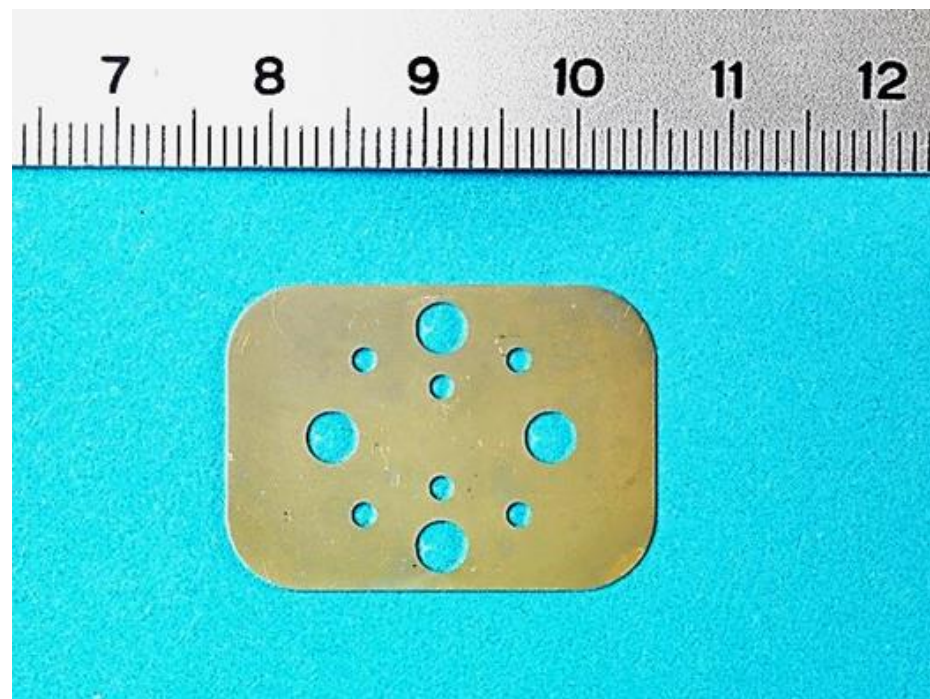
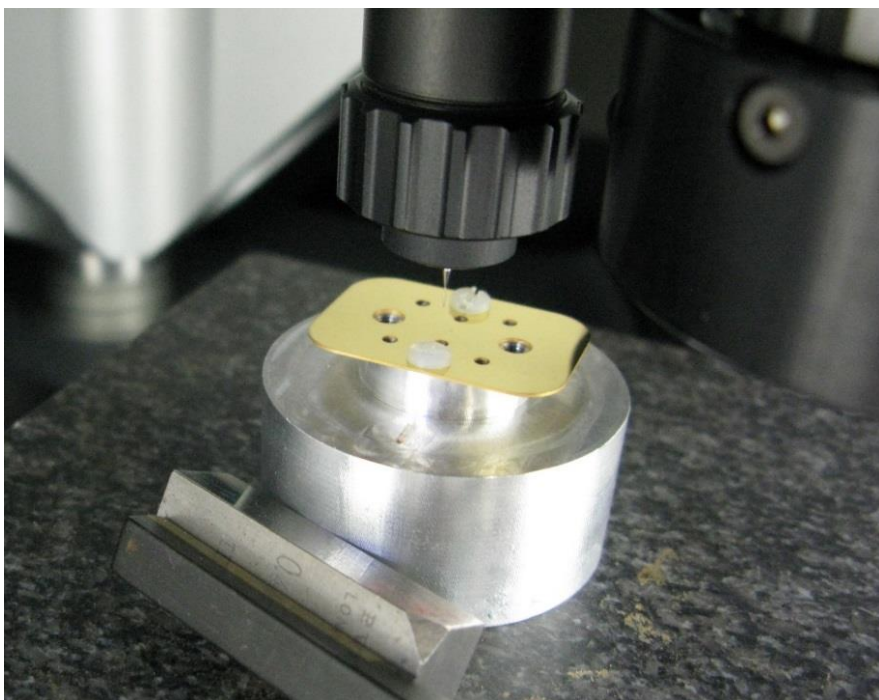
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Dimensions measured using  
probe/vision systems

CMM (Coordinate Measuring Machines)

Waveguide apertures and flanges

New IEEE standards (1785)



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Three new standards:

“IEEE Standard for Rectangular Metallic Waveguides and Their Interfaces for Frequencies of 110 GHz and Above”

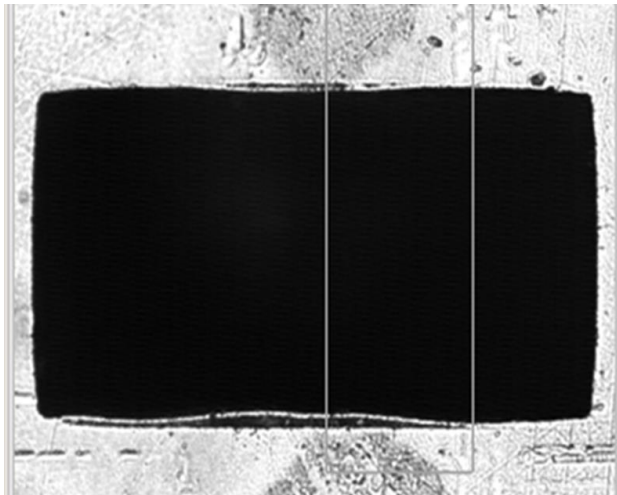
- IEEE Std 1785.1-2012
- IEEE Std 1785.2-2016
- IEEE Std 1785.3-2016



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

IEEE Std 1785.1-2012

Part 1: “Frequency Bands and Waveguide Dimensions”



IEEE STANDARDS ASSOCIATION



## IEEE Standard for Rectangular Metallic Waveguides and Their Interfaces for Frequencies of 110 GHz and Above— Part 1: Frequency Bands and Waveguide Dimensions

IEEE Microwave Theory and Techniques Society

Sponsored by the  
Standards Coordinating Committee

IEEE  
3 Park Avenue  
New York, NY 10016-5997  
USA

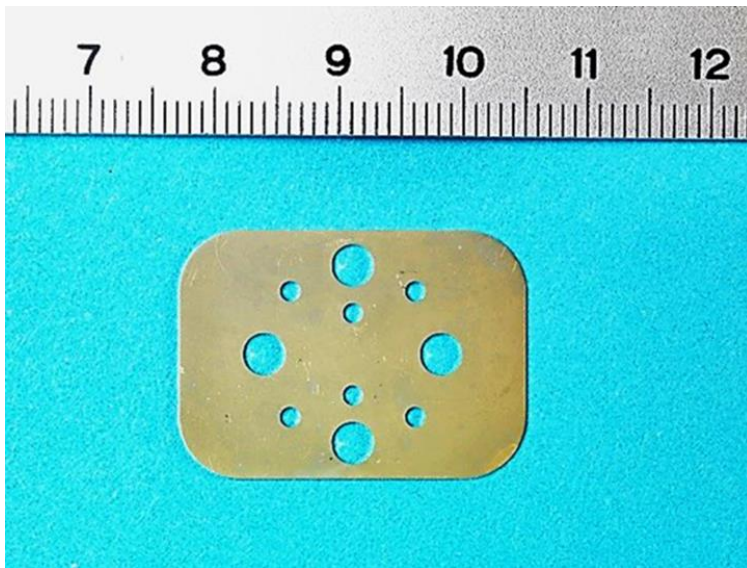
IEEE Std 1785.1™-2012

1 March 2013

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

IEEE Std 1785.2-2016

Part 2: “Waveguide Interfaces”



IEEE STANDARDS ASSOCIATION

IEEE

**IEEE Standard for Rectangular Metallic  
Waveguides and Their Interfaces for  
Frequencies of 110 GHz and Above—**

**Part 2: Waveguide Interfaces**

IEEE Microwave Theory and Techniques Society

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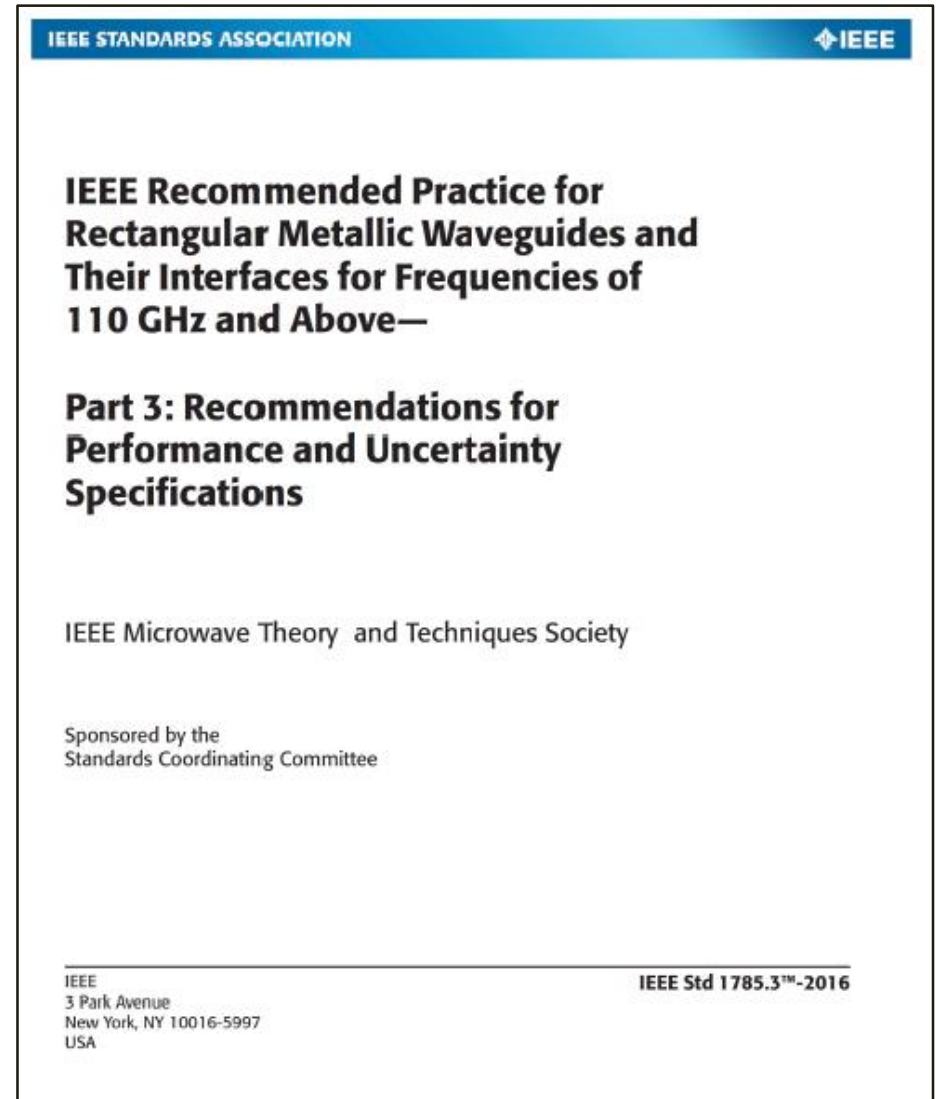
IEEE Std 1785.2™-2016

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

IEEE Std 1785.3-2016

Part 3:

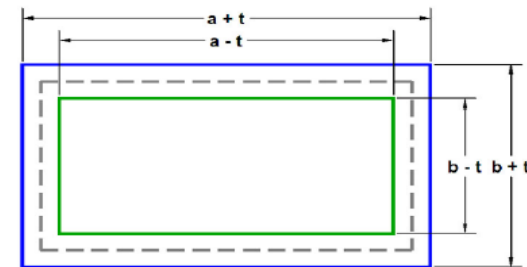
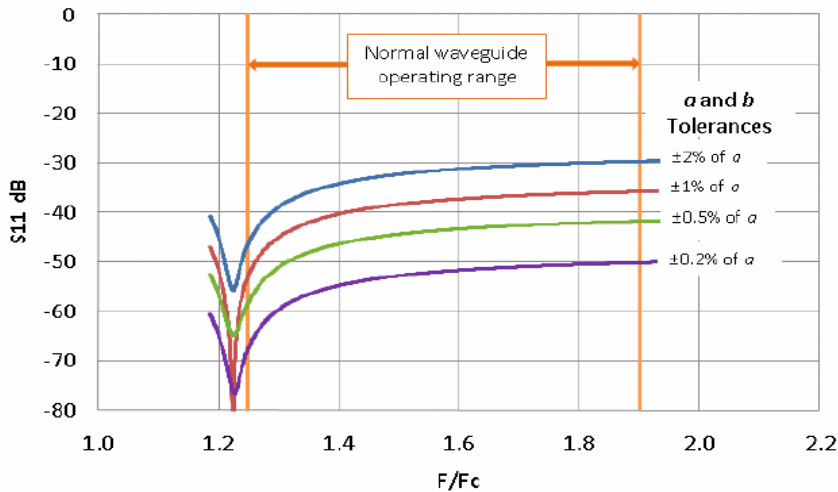
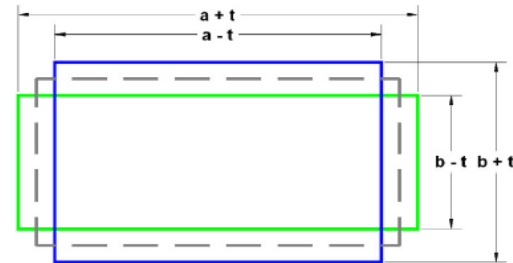
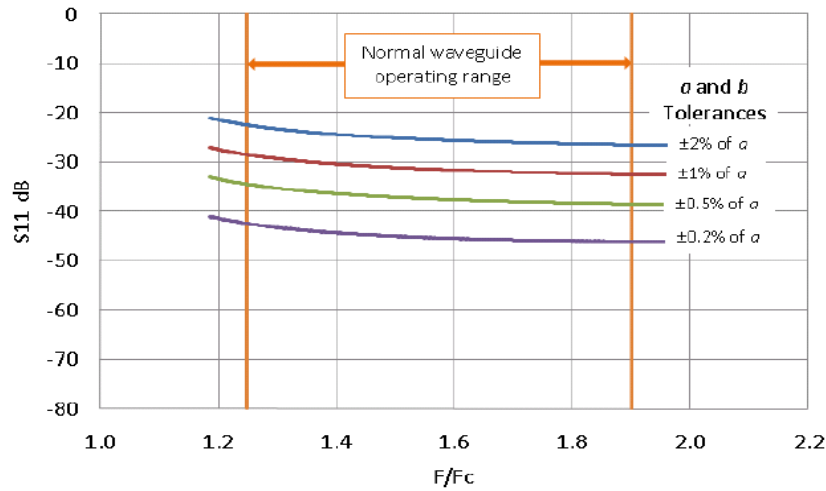
“Recommendations for Performance and Uncertainty Specifications”





# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

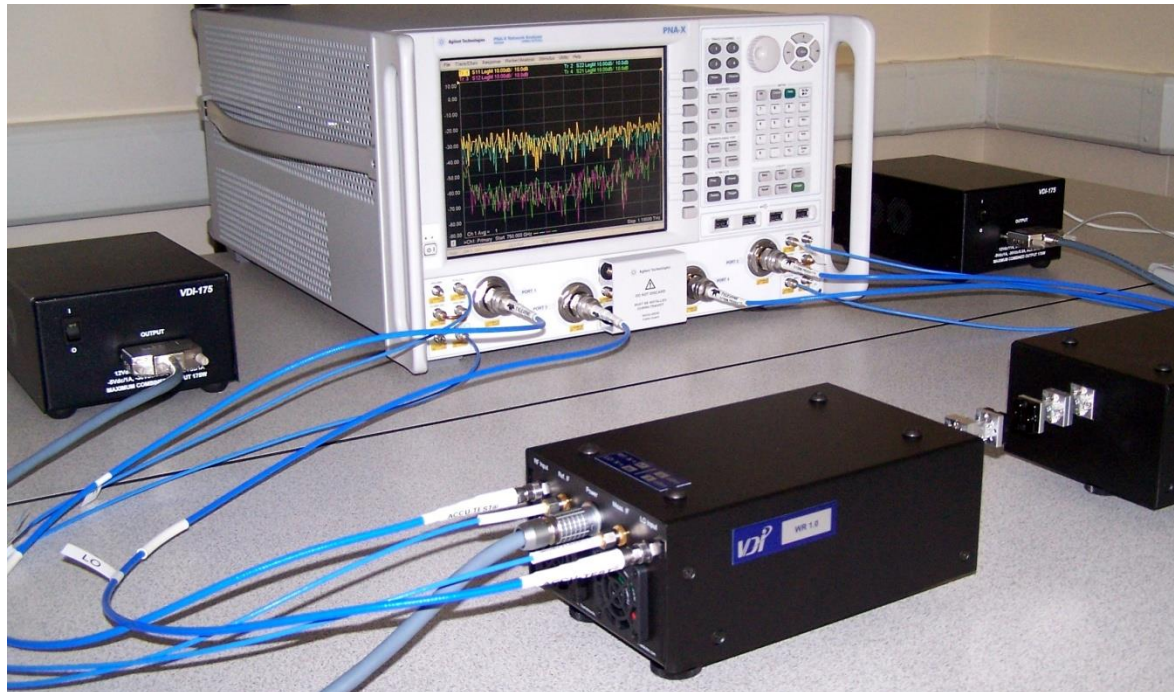
## Effects of waveguide aperture and interface tolerances



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Waveguide measurement capability

- Vector Network Analyser (VNA) with high precision calibration kits
- University of Leeds / NPL partnership: Traceable VNA to 1.1 THz

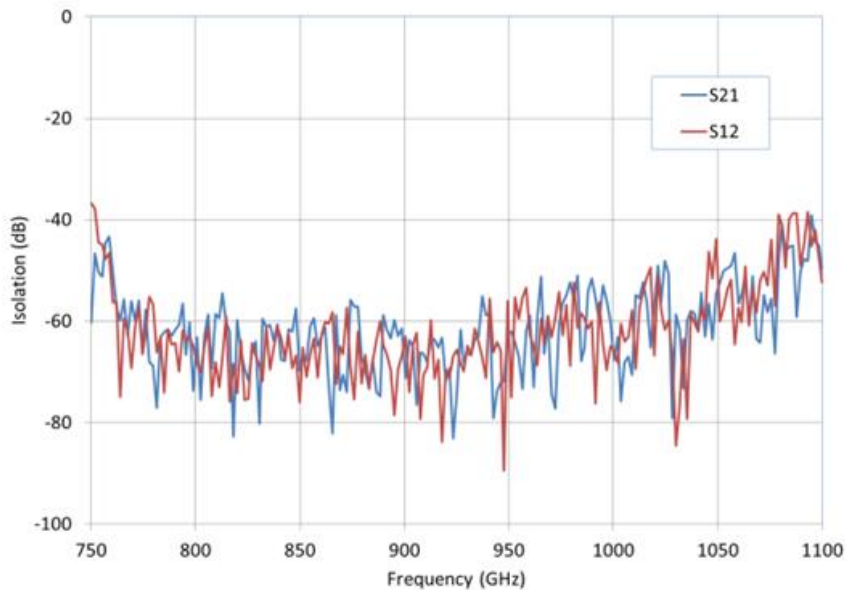


# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

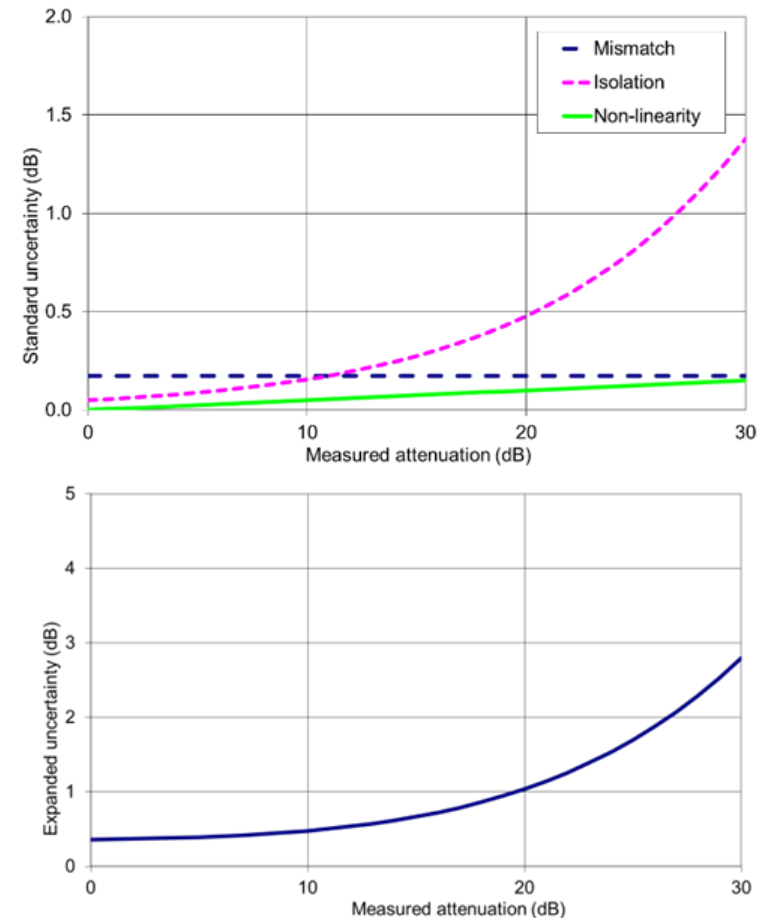
University of Leeds / NPL

traceable measurements to 1.1 THz

VNA dynamic range (60 dB)



VNA accuracy (3 dB @ 30 dB)



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Filling the gap between microwaves and photonics

Remaining challenges:

- Key Comparisons and CMCs in the 0.1 THz to 1.0 THz range
- Establish traceability services offering *comprehensive* frequency coverage
- Establish *regional* metrology facilities – in Asia, Europe, North America, etc
- What about > 1 THz ??

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

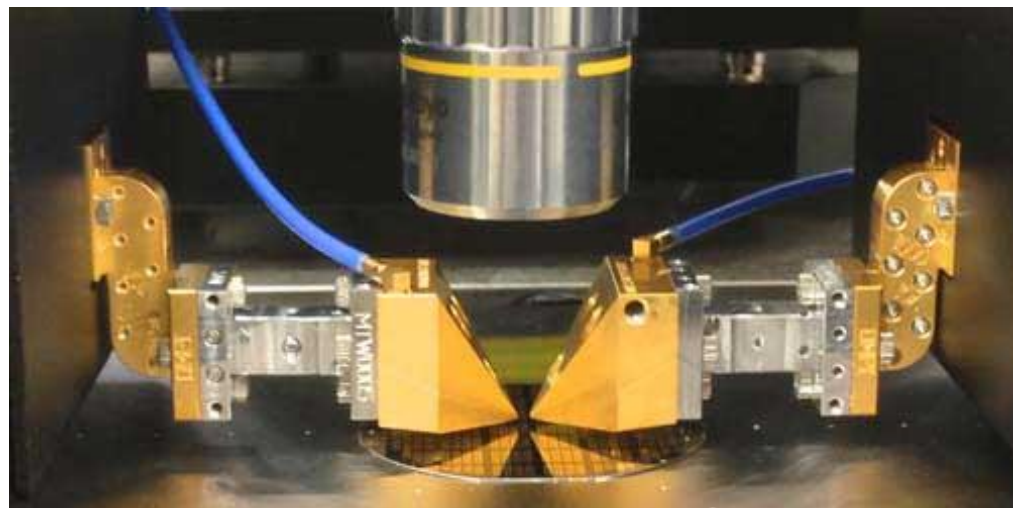
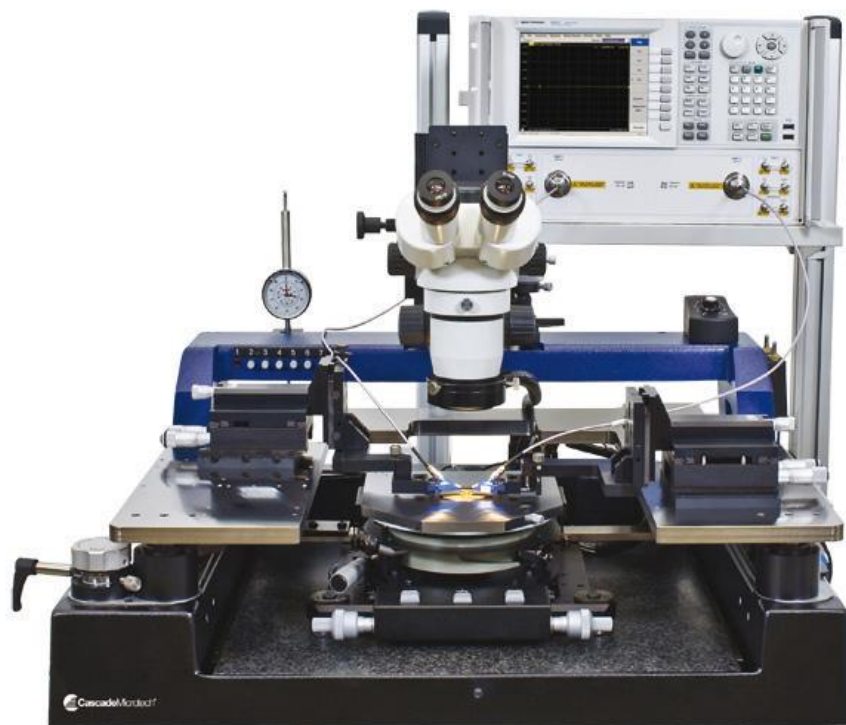
New measurements . . . going from GHz to THz

- Instrumentation – waveguides
- **Devices – on-wafer**

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Most devices are on a planar wafers

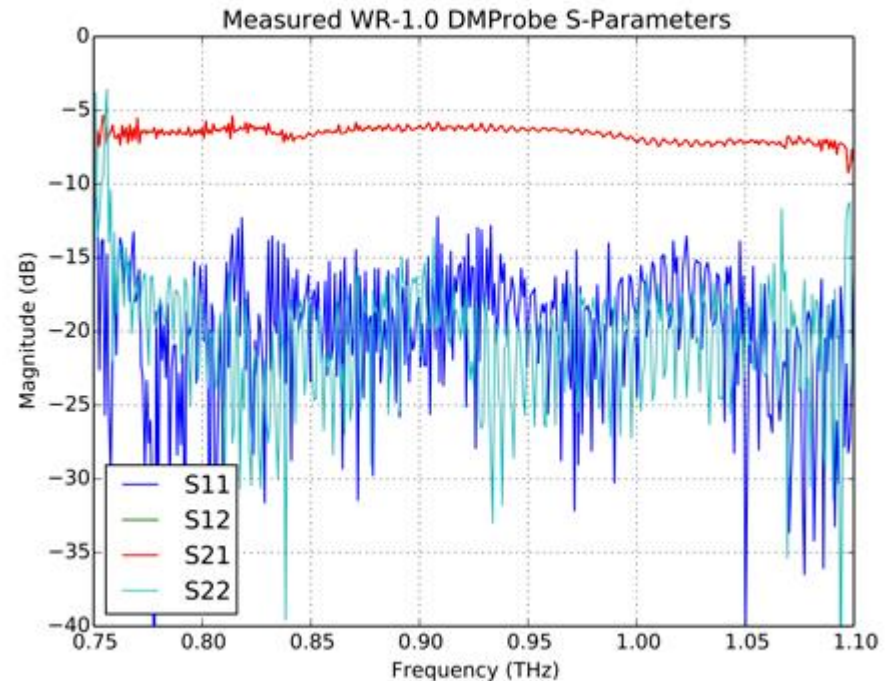
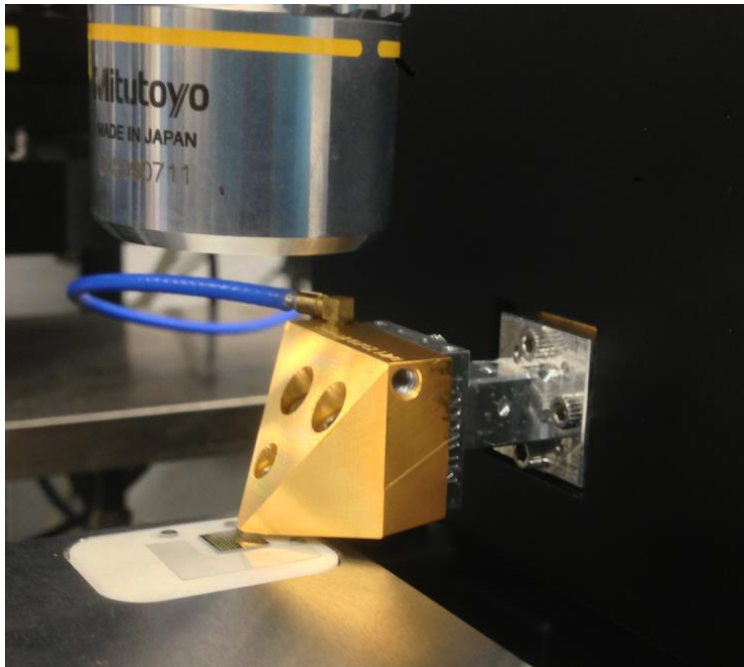
- We need a probe station and on-wafer probes to do measurements





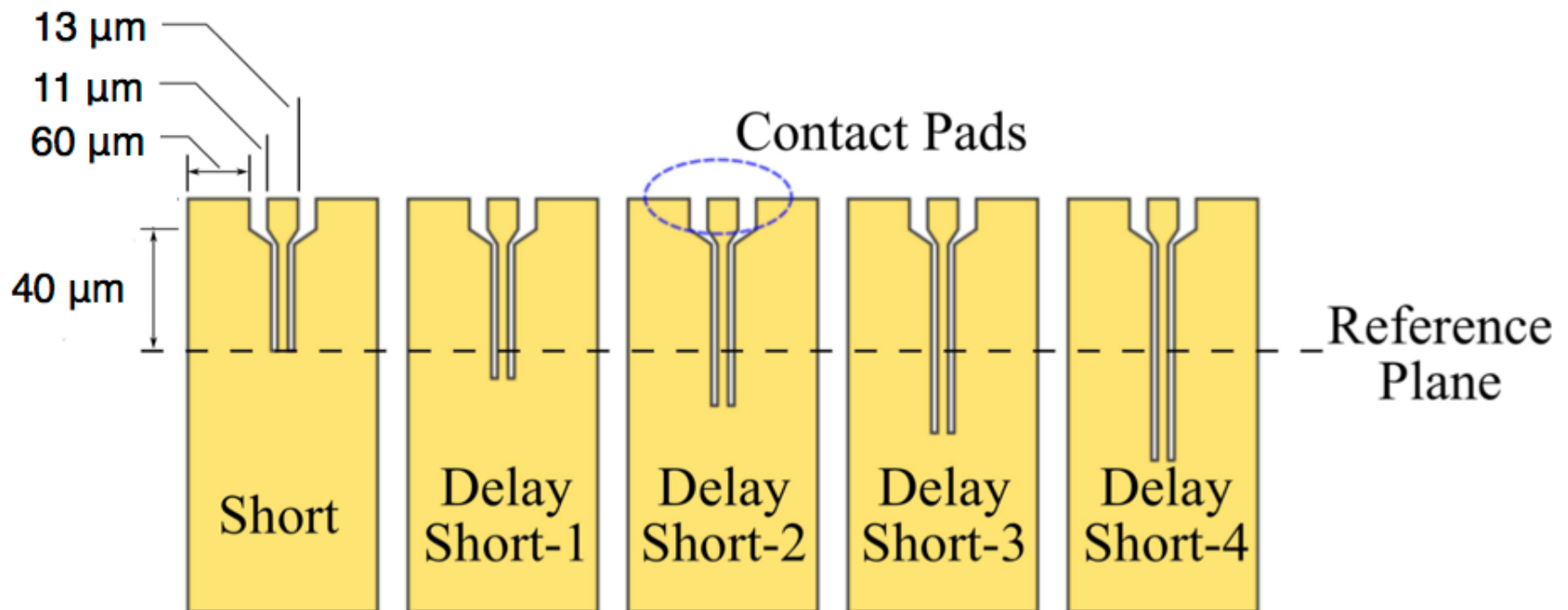
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

For on-wafer measurements, best to calibrate at probe tips using on-wafer standards: 750 GHz to 1.1 THz



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

- On-wafer calibration kits (calibration substrates)





# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Filling the gap between microwaves and photonics

Remaining challenges:

- Measurement traceability!! . . . Yes or no??  
(there is still no on-wafer traceability, even after >25 years)
- Many scientific challenges relating to very short wavelength propagation
- Many technological challenges due to differing dimensions and materials
- Establish *regional* metrology capabilities – in Asia, Europe, North America, etc

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Next topic . . .

I. Filling the gap between microwaves and photonics

**II. Multi-physics – more than just microwaves**

III. When digital becomes analogue

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Multi-physics – more than just microwaves

Application area . . .

### Telecommunications

- 5G and beyond
- Machine to Machine (M2M)
- Internet of Things (IoT)
- RF Nano-technology

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## The start of the communications revolution . . .

Alexander Graham Bell at the opening of the long-distance telephone line from New York to Chicago in 1892

(125 years ago)



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Modern communications devices (power amplifiers, etc) require an holistic (multi-physics) approach to device testing

- Microwave measurements
  - ... and*
- Electromagnetic near-field scanning
  - ... and*
- Thermal imaging

*It would be great to do all this, at the same time !!*

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

This approach is available at n3m-labs (the Nonlinear Microwave Measurement & Modelling Laboratories) at the University of Surrey and NPL in the UK

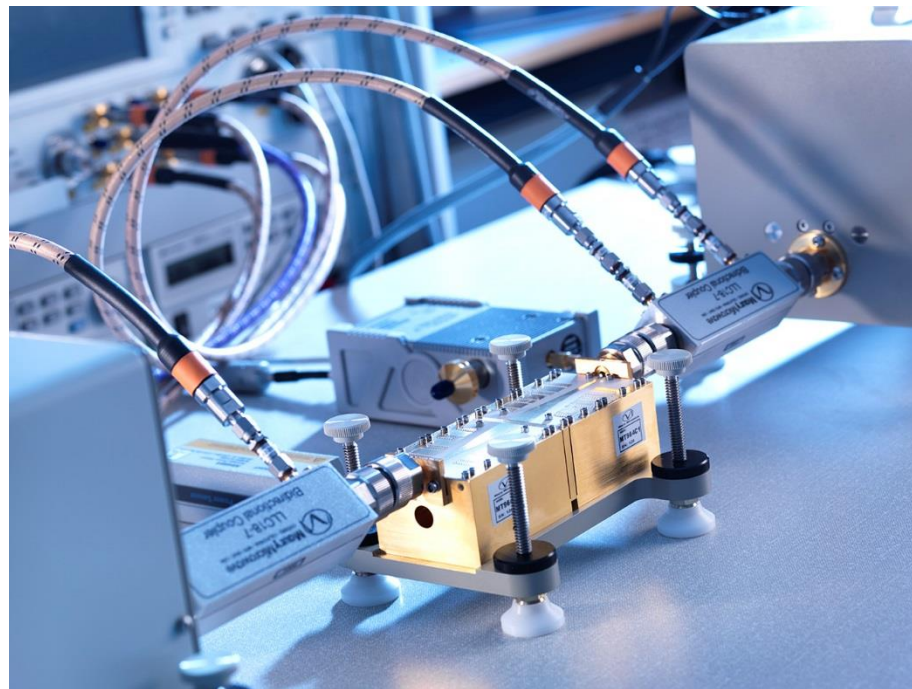
n3m-labs was opened in June 2016





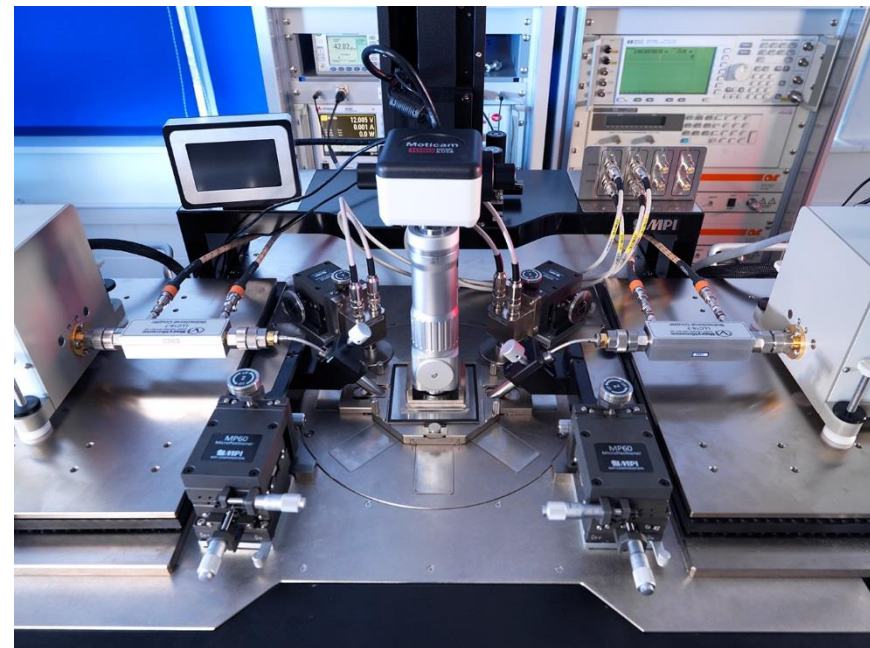
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Fixtured microwave measurements – large-signal; passive/active harmonic loadpull



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

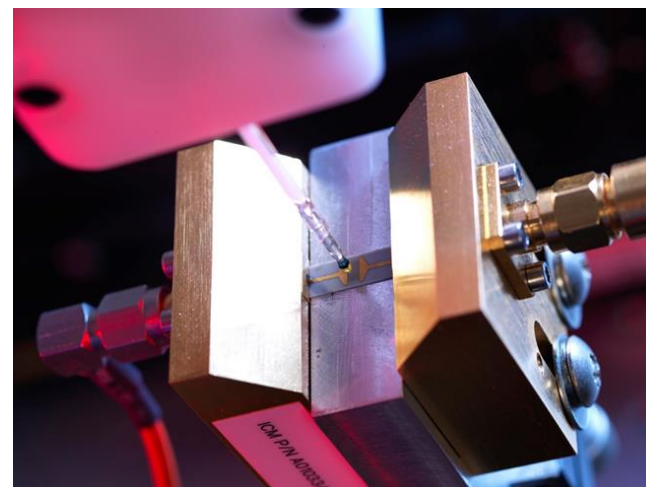
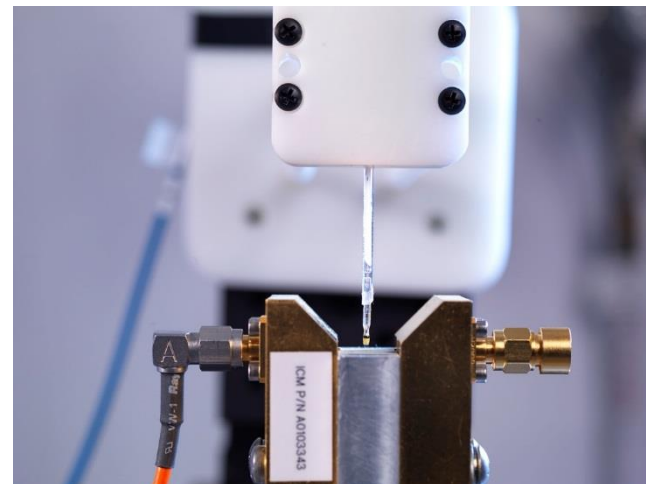
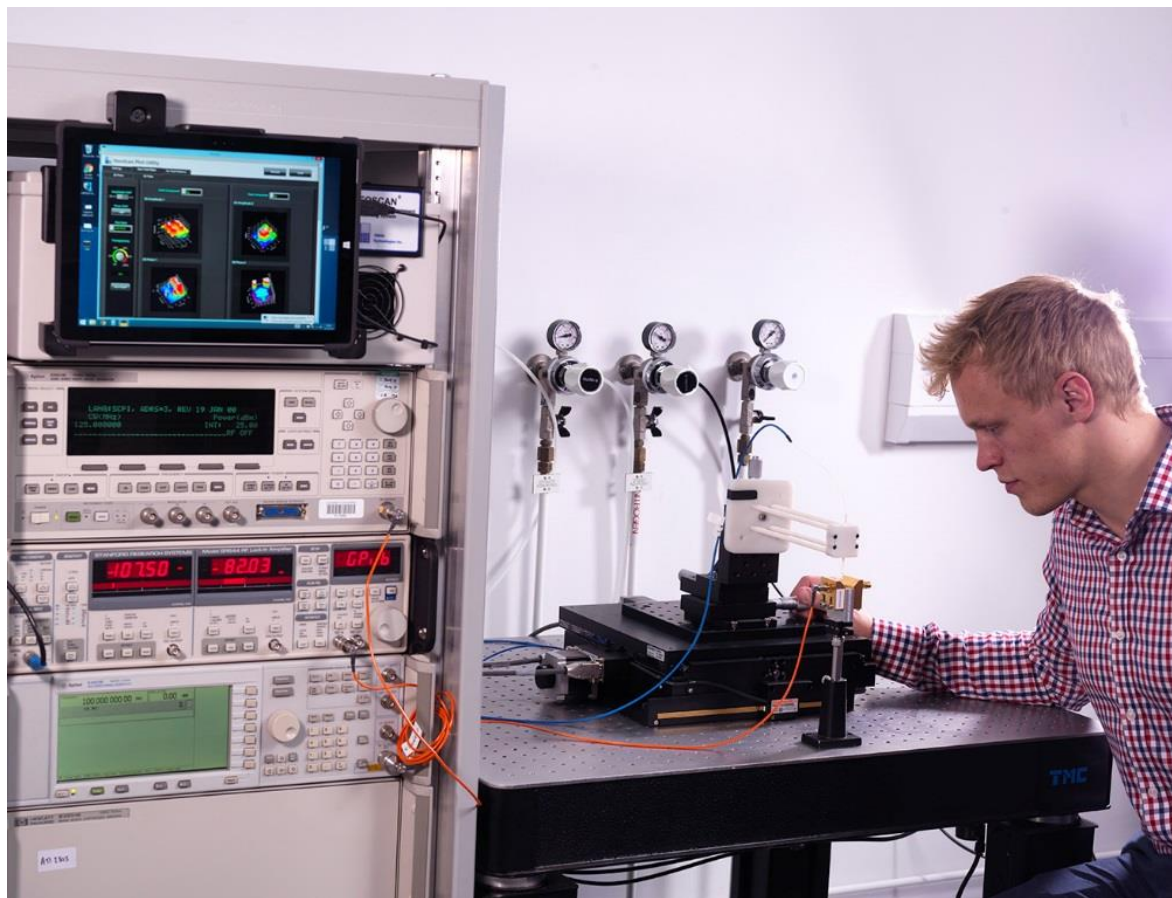
On-wafer microwave measurements – large-signal; passive/active harmonic loadpull





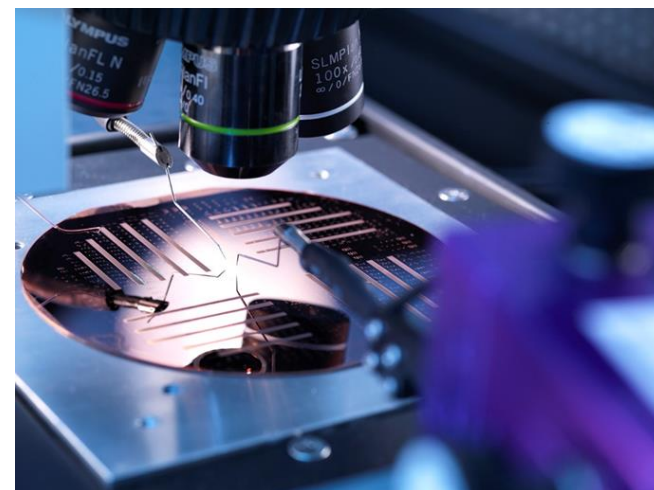
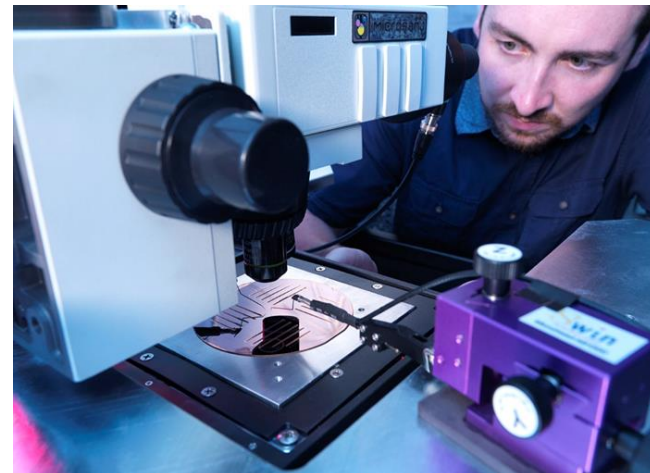
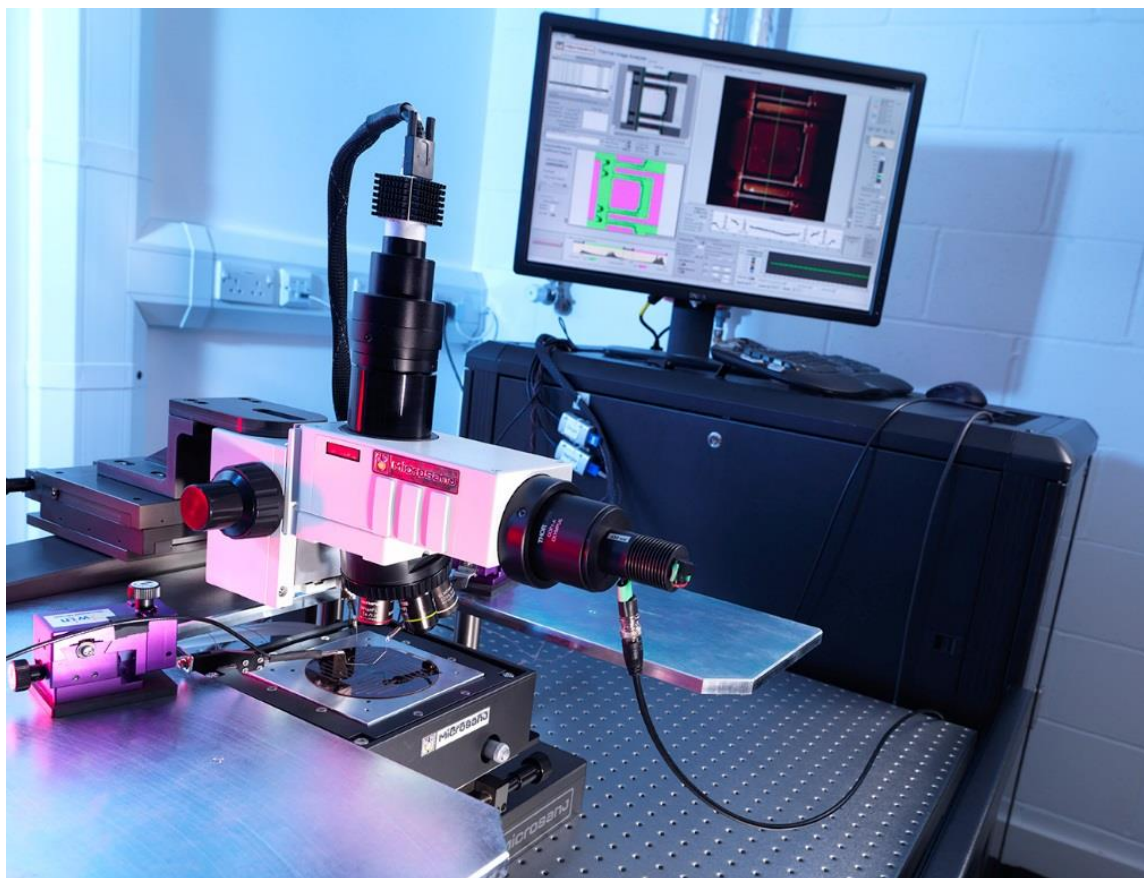
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Electromagnetic near-field scanning



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Thermal imaging





# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## n3m-labs capabilities:

- On-wafer/fixtures passive/active harmonic loadpull
- Two Nonlinear VNAs to 67 GHz
- High power RF sources
- On-wafer probe station (temperature:  $-40\text{ }^{\circ}\text{C}$  to  $+200\text{ }^{\circ}\text{C}$ )
- High-resolution thermal imaging (0.25  $\mu\text{m}$  and 50 ns)
- Near-field electromagnetic scanner
- Nonlinear device modelling software
- Compute cluster: 1064 cores, 5.5 TB RAM, GPUs...
- UK primary national measurement standards



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Multi-physics – more than just microwaves

Remaining challenges :

- Traceability for ‘new’ non-linear measurands (X-parameters, etc)
- Source-pull and Load-pull measurements (  $Z_0 \neq 50$  ohms)
- Uncertainties in measurement-derived models
- Measurement site-to-site reproducibility

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Final topic . . .

- I. Filling the gap between microwaves and photonics
- II. Multi-physics – more than just microwaves
- III. When digital becomes analogue**

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## When digital becomes analogue

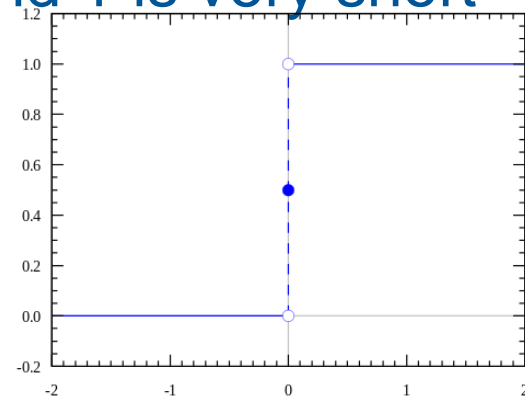
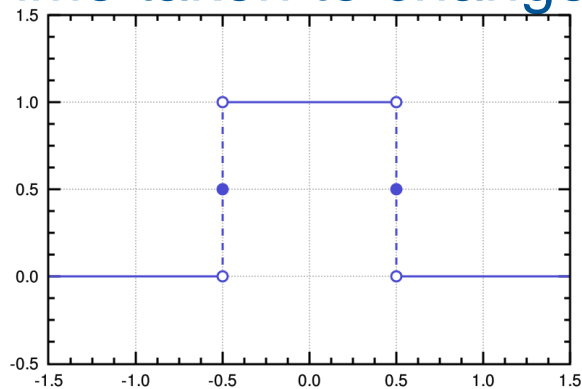
### Applications:

- Computing
- Internet of Things (IoT)
- High-speed electronics (interconnects)
- Games (Wii, Playstation, Xbox)

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Key technology: Printed Circuit Boards (PCBs) and component interconnects

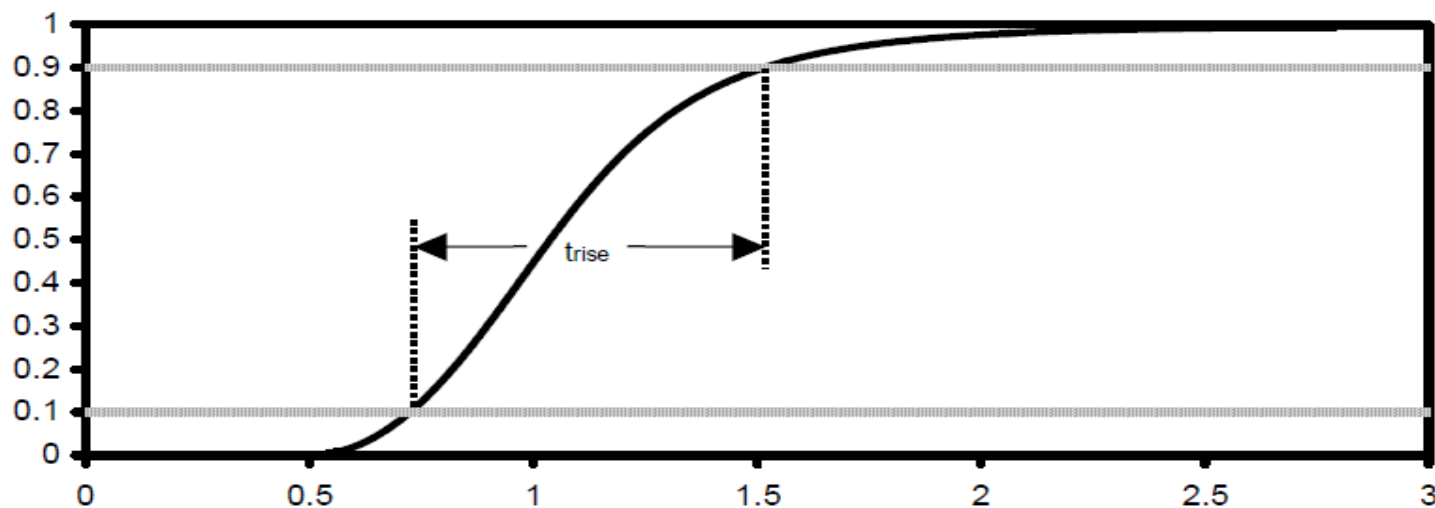
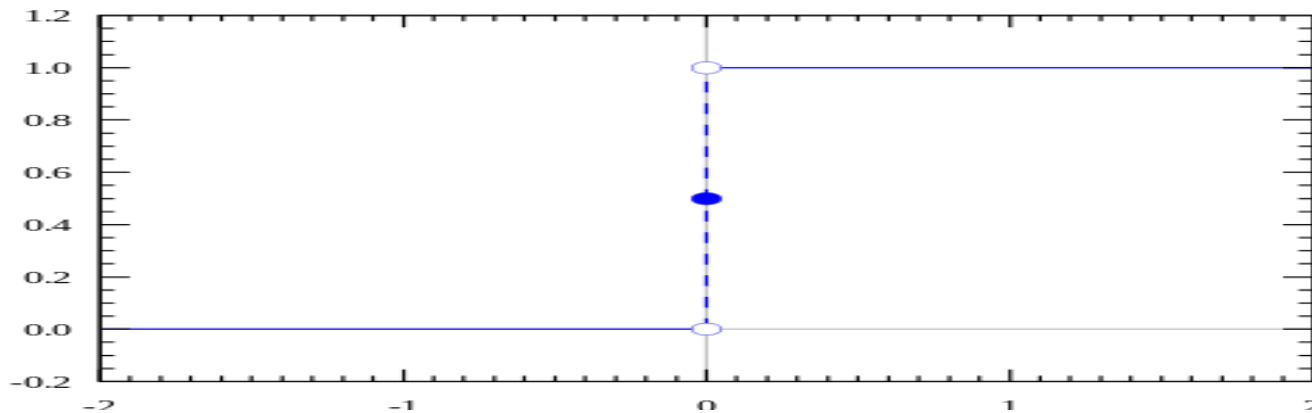
- Digital signals (ones and zeros: 1, 0, 0, . . . , 0, 1, . . . )
- Time taken to change between 0 and 1 is very short



- Leading edge contains many high frequency components

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## 1. Pulse risetime

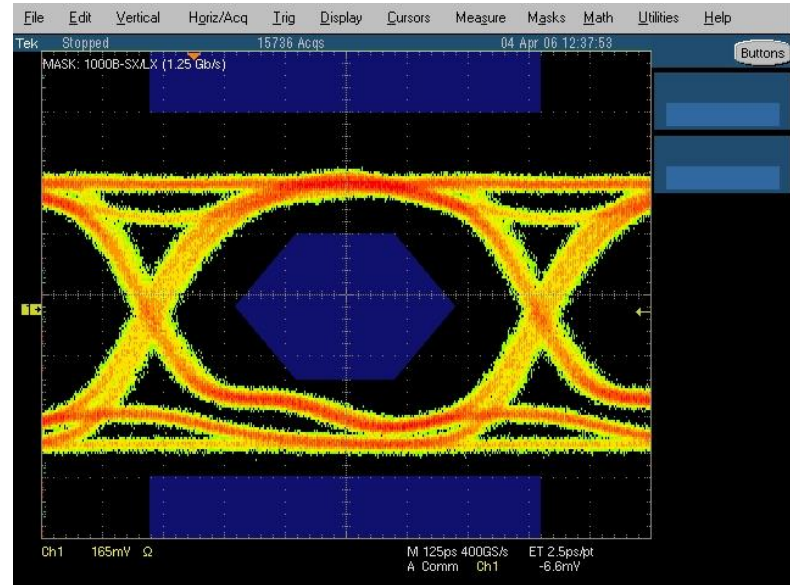




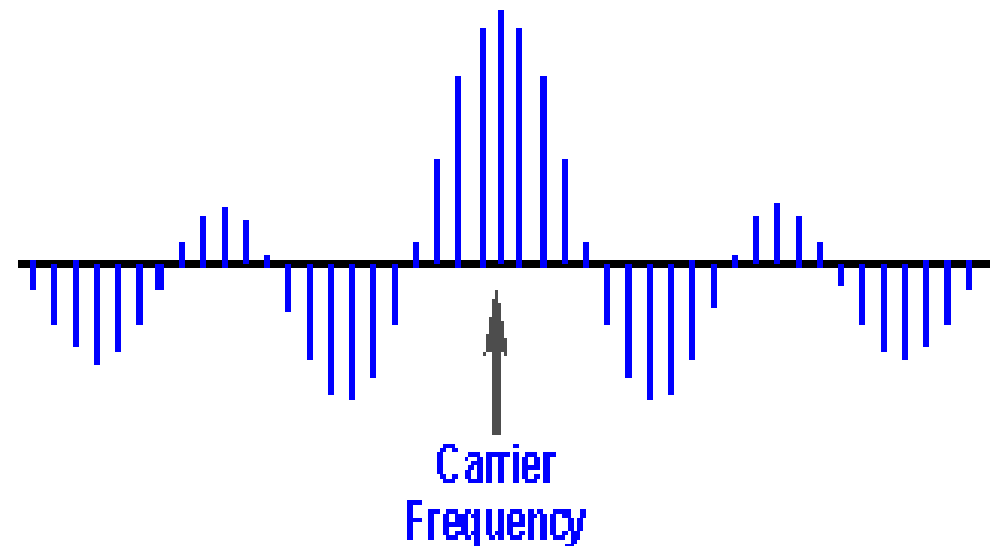
# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Risetime (seconds):  
bandwidth (hertz)

$$RT = \frac{0.35}{BW}$$



Risetime = 10 ps  
Bandwidth = **35 GHz**



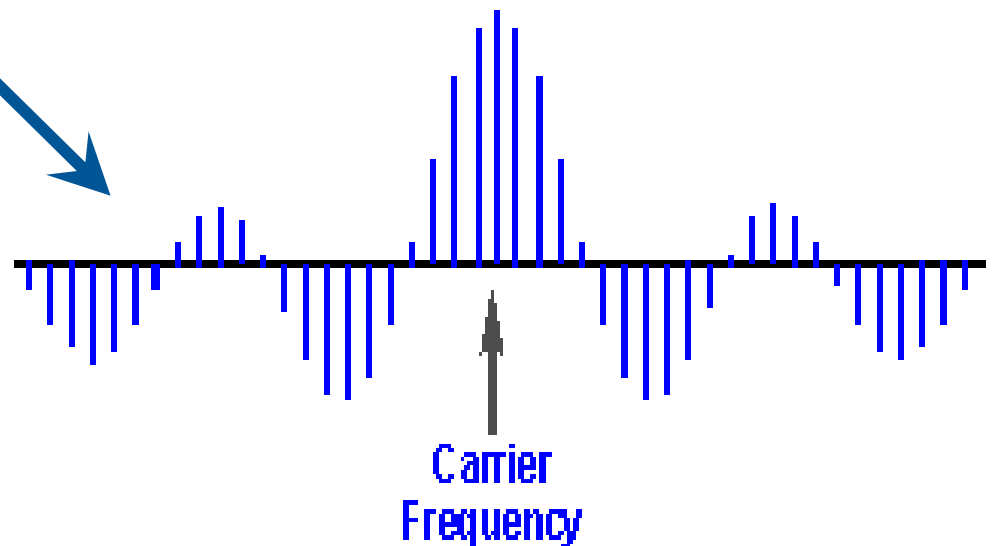
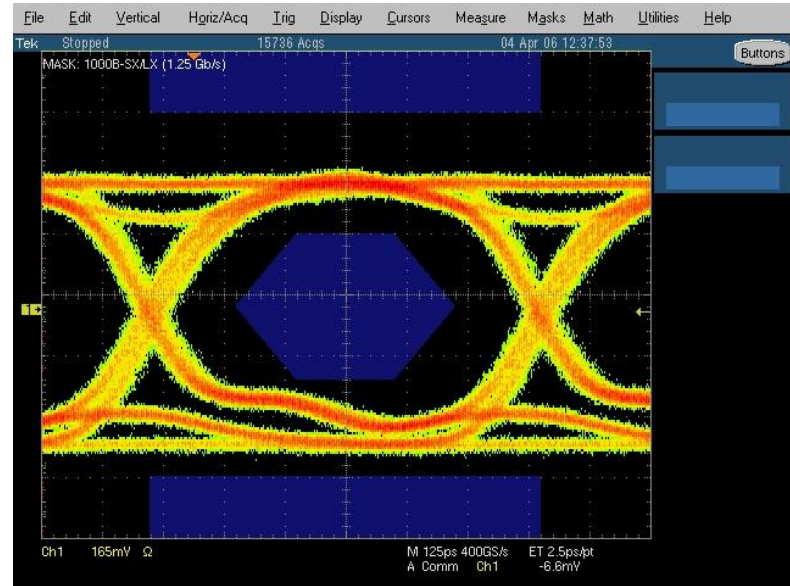
**mm-wave frequencies!**

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

For measurements,  
we need:

Time-domain  
*and*

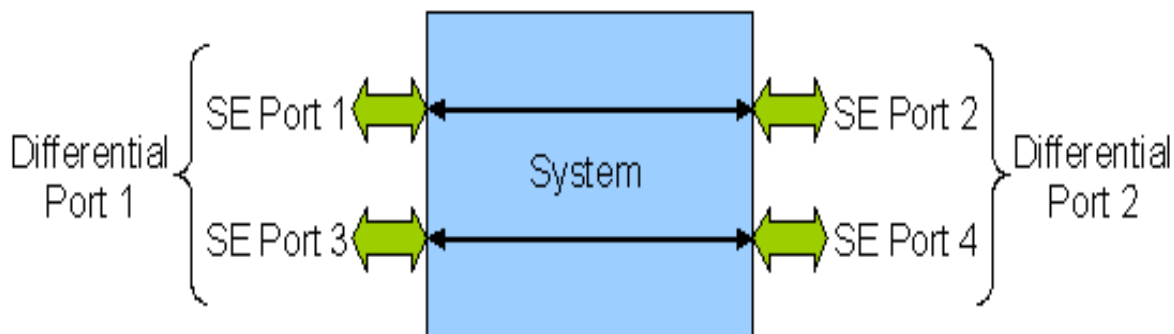
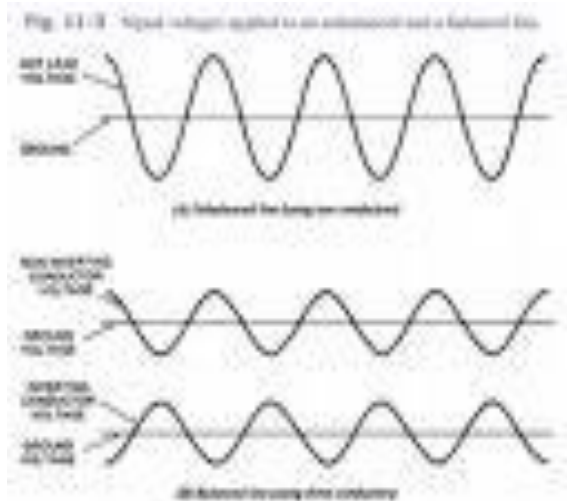
Frequency-domain



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## 2. PCB component packing/interconnect – very high density

- Use differential signals to avoid component-to-component interference

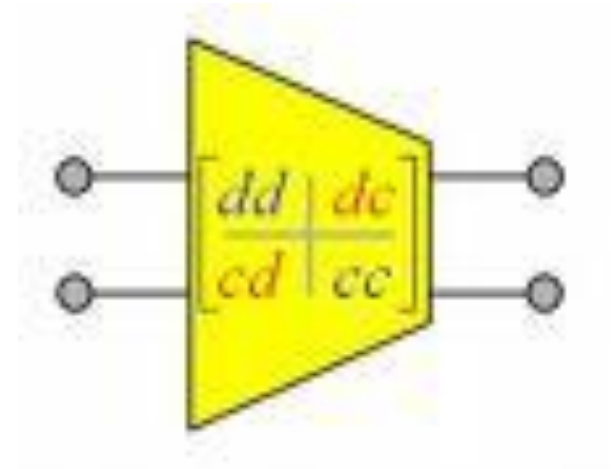


# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

For measurements, we need:

Mixed-mode S-parameters:

- Differential-mode (DD)
- Common-mode (CC)
- Mode conversion: differential-to-common and vice versa (CD, DC)

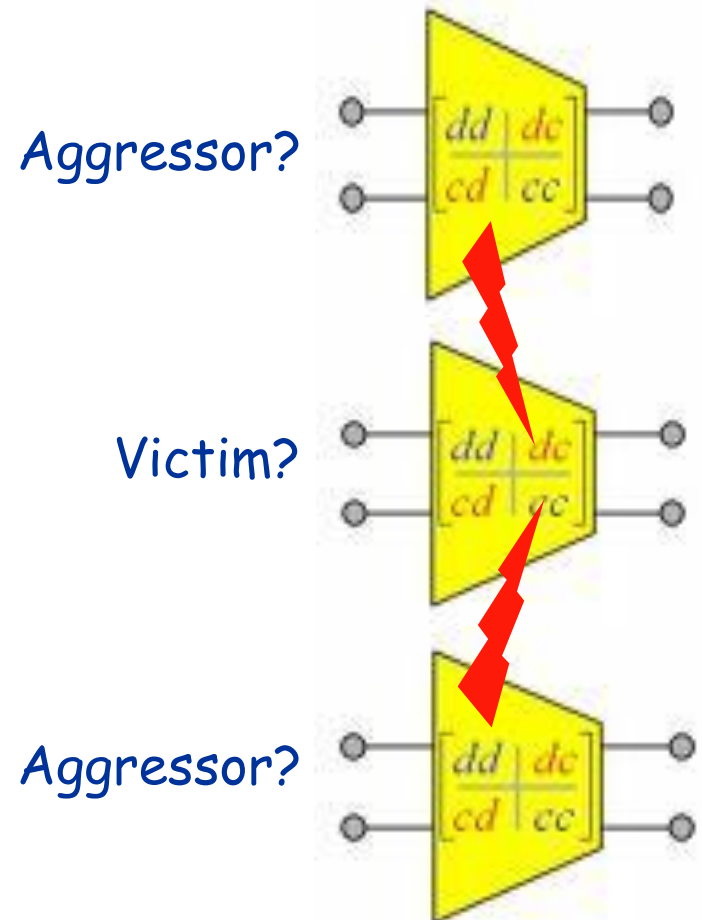


$$\left( \begin{array}{cc|cc} S_{DD,11} & S_{DD,12} & S_{DC,11} & S_{DC,12} \\ S_{DD,21} & S_{DD,22} & S_{DC,21} & S_{DC,22} \\ \hline S_{CD,11} & S_{CD,12} & S_{CC,11} & S_{CC,12} \\ S_{CD,21} & S_{CD,22} & S_{CC,21} & S_{CC,22} \end{array} \right)$$

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Component interference “victims” and aggressors”

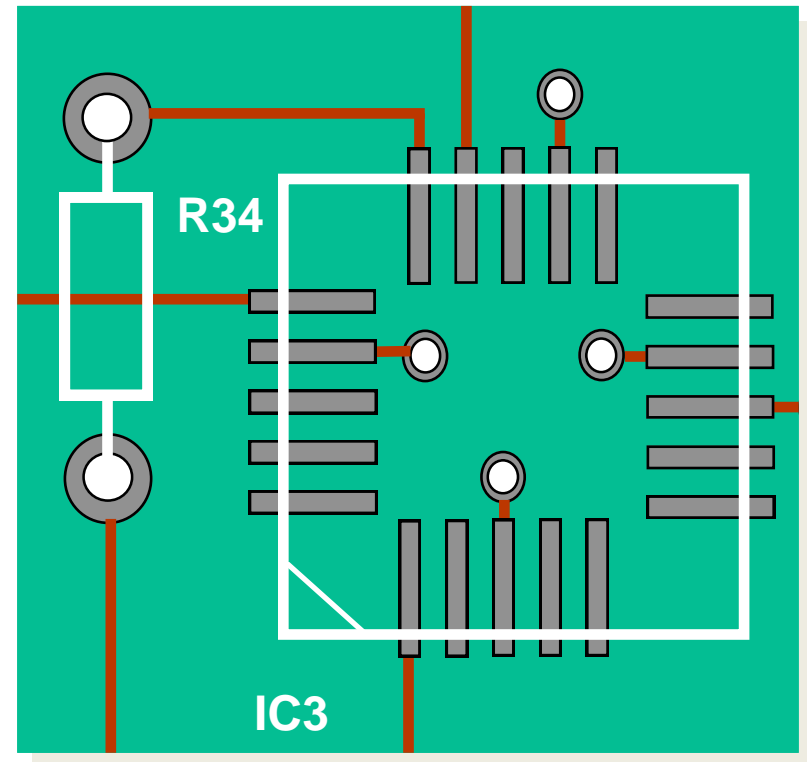
- 3 devices
- Each device has 4 connections
- We need 12 “ports” to make these measurements



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## 3. Multilayer PCBs

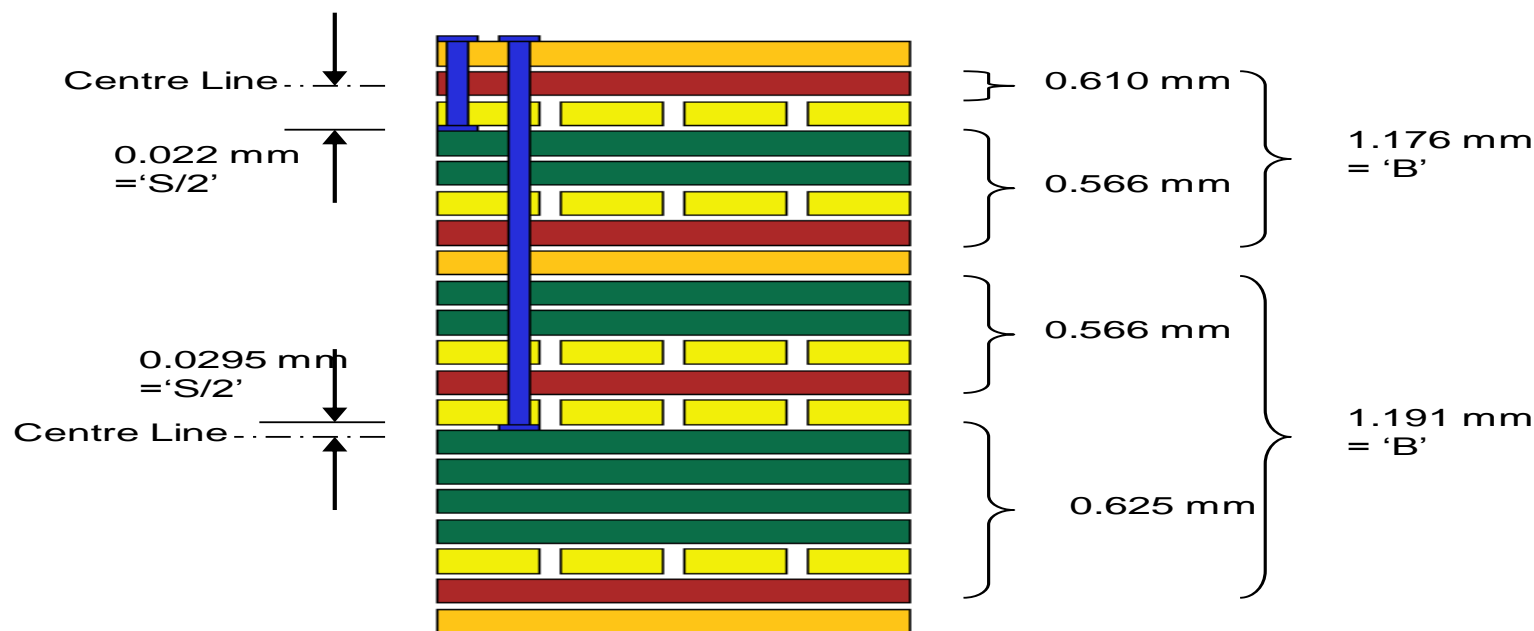
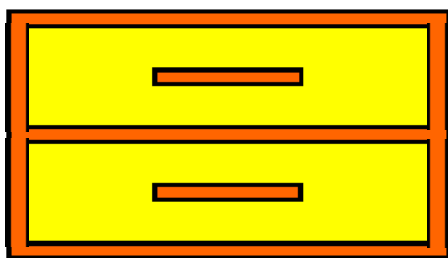
- Involves conductors and dielectrics sandwiched together
- Connections to embedded layers are difficult
- Via holes are drilled through layers to help with interconnects





# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Multi-layer PCBs

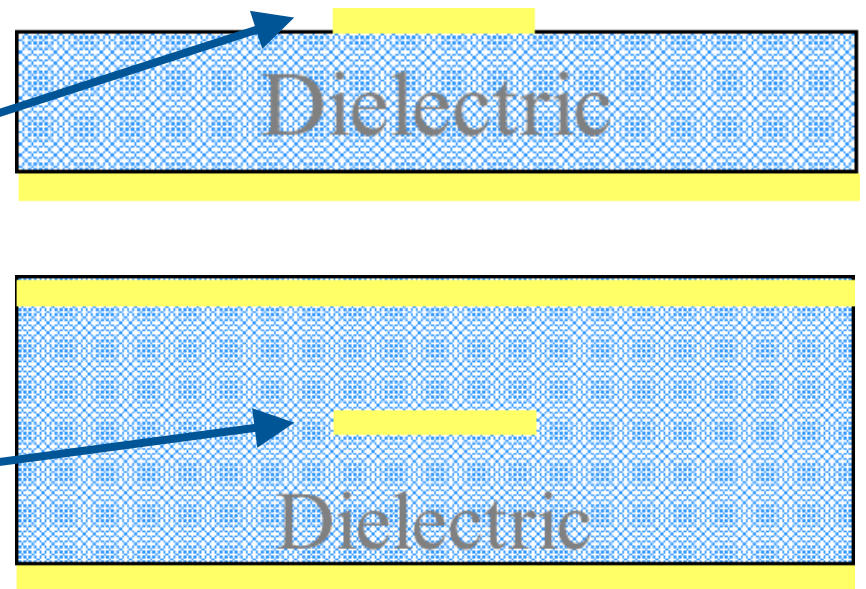


# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

PCBs with several layers

Two types of transmission line:

- Microstrip
- Stripline



# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Combined measurement architecture:

- Time-domain / Frequency-domain – for Signal Integrity assessments
- Differential signals – mixed-mode S-parameters
- Multi-port devices – for victims and aggressors assessments
- Multi-layer microstrip / stripline transmission lines

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

## Remaining challenges – when digital becomes analogue:

- Traceability and/or Best Practice on PCBs:
  - Time-domain / Frequency-domain equivalence
  - Mixed-mode S-parameters
  - Multi-layer PCBs
  
- Provide input to industry-level standards-making: IEEE (P370), IPC (TM650), etc
  
- ‘Wire’ interconnects at the nano-scale
  
- Establish *regional* metrology capabilities – in Asia, Europe, North America, etc

# Future challenges in high-frequency electromagnetic metrology (RF to terahertz)

Topics I haven't discussed (but are still very important):

- Terahertz time-domain systems (spectrometers, etc)
- Antenna beam-forming techniques for mm-wave communications
- Extreme impedance measurements for emerging nano-materials (graphene, etc)

# Further reading – THz metrology

- *The 2017 Terahertz Science and Technology Roadmap*  
46 co-authors, J Phys D, Vol 50, No 4, 043001 (49pp), Feb 2017
- *Metrology State-of-the-art and Challenges in Broadband Phase-sensitive Terahertz Measurements*  
M Naftaly, R G Clarke, D A Humphreys, N M Ridler, Proc IEEE, Jan 2017
- *Establishing Traceability to the International System of Units for Scattering Parameter Measurements from 750 GHz to 1.1 THz*  
N M Ridler, R G Clarke, IEEE Trans TST Vol 6, No 1, pp 2-11, Jan 2016
- *Terahertz Metrology*  
Mira Naftaly (Editor), Artech House, 2015